Special Issue

Machine Learning Methods for Modelling Neurological Diseases

Message from the Guest Editors

For this Special Issue, we seek research that demonstrates the application of Machine Learning methods in the modelling of neurological disorders, spanning from neurodevelopmental to neurodegenerative and age-related disorders. Potential topics include (but are not limited to): - Machine Learning approaches in neurodevelopmental disorders- Machine Learning approaches in neurodegenerative disorders- Machine Learning in aging and age-related disorders- Machine Learning in neuromuscular diseases- Machine Learning in the diagnosis of neurological disorders- Multimodal data collection and analysis- Data fusion in neurology- Hardware and software integration- Health and care applications

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